

**Electronic Supplementary Information for**

**Three-dimensional polyaniline architecture enabled by hydroxyl-terminated  
Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> MXene for high-performance supercapacitor electrodes**

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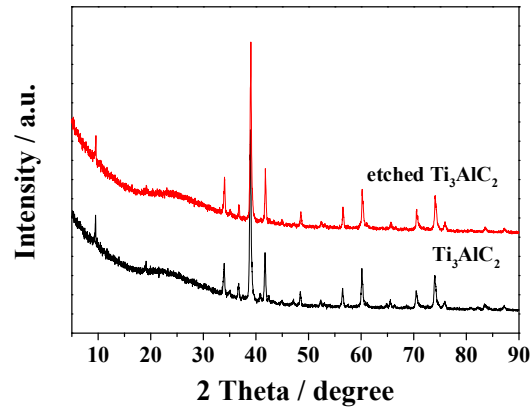


Fig. S1 XRD patterns of  $\text{Ti}_3\text{AlC}_2$  before NaOH etching processes and etched  $\text{Ti}_3\text{AlC}_2$  after NaOH etching processes.

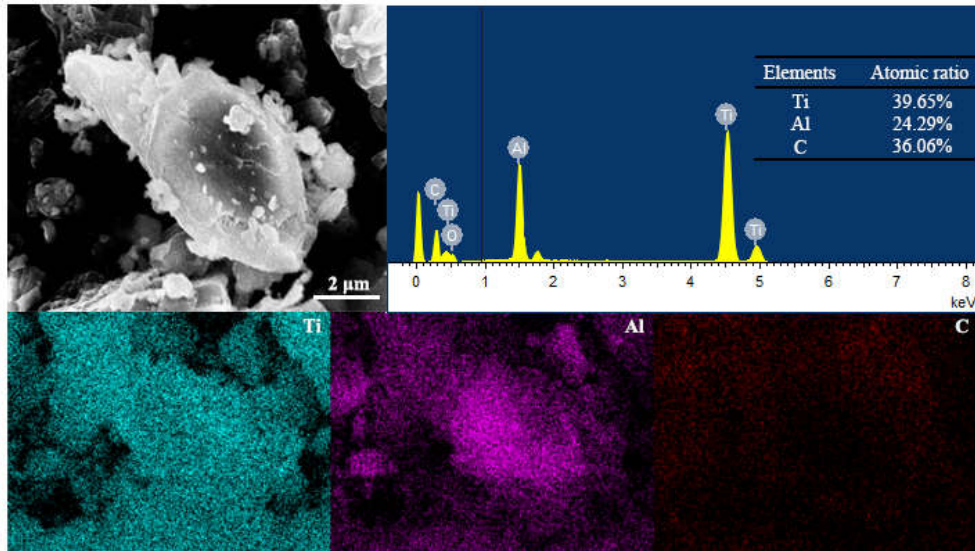


Fig. S2 SEM image, EDS spectra and element mapping distributions of  $\text{Ti}_3\text{AlC}_2$  before NaOH etching processes.

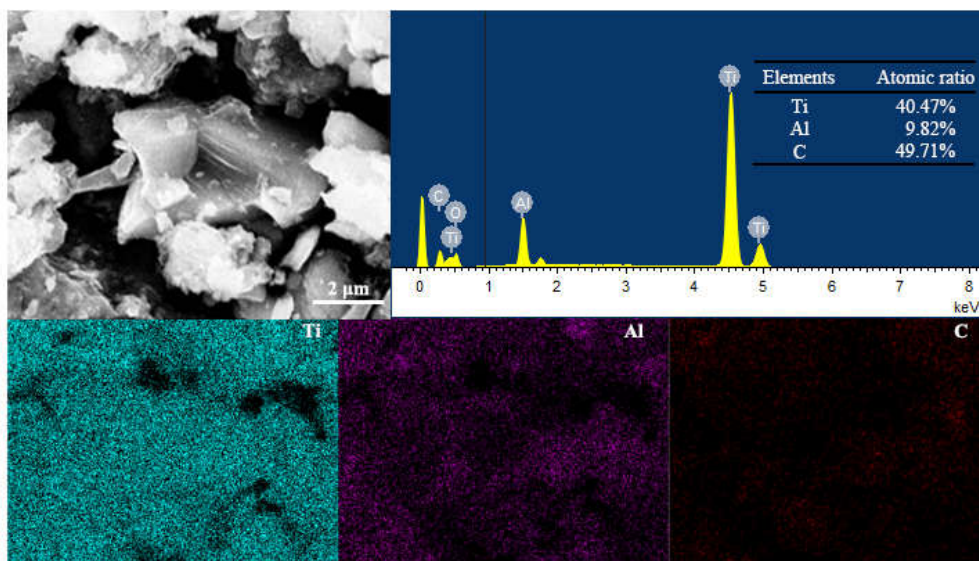


Fig. S3 SEM image, EDS spectra and element mapping distributions of etched  $\text{Ti}_3\text{AlC}_2$  after NaOH etching processes.

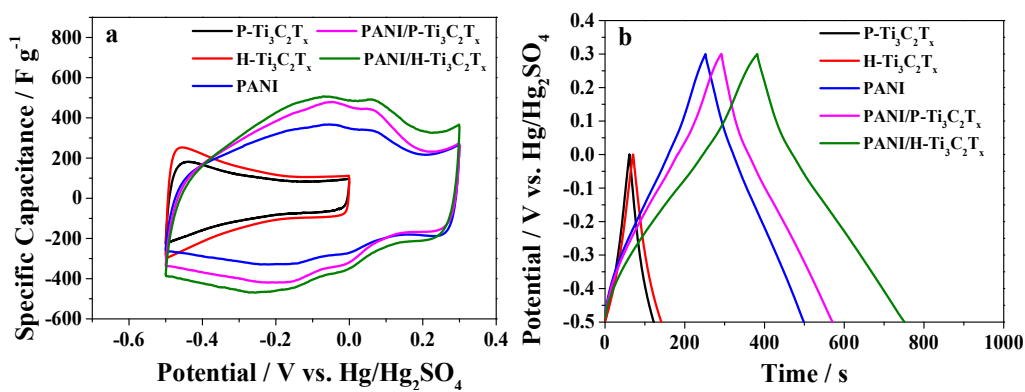


Fig. S4 Comparison of electrochemical performance for all the samples: (a) CV curves at  $10 \text{ mV s}^{-1}$ . (b) GCD curves at  $1 \text{ A g}^{-1}$ .

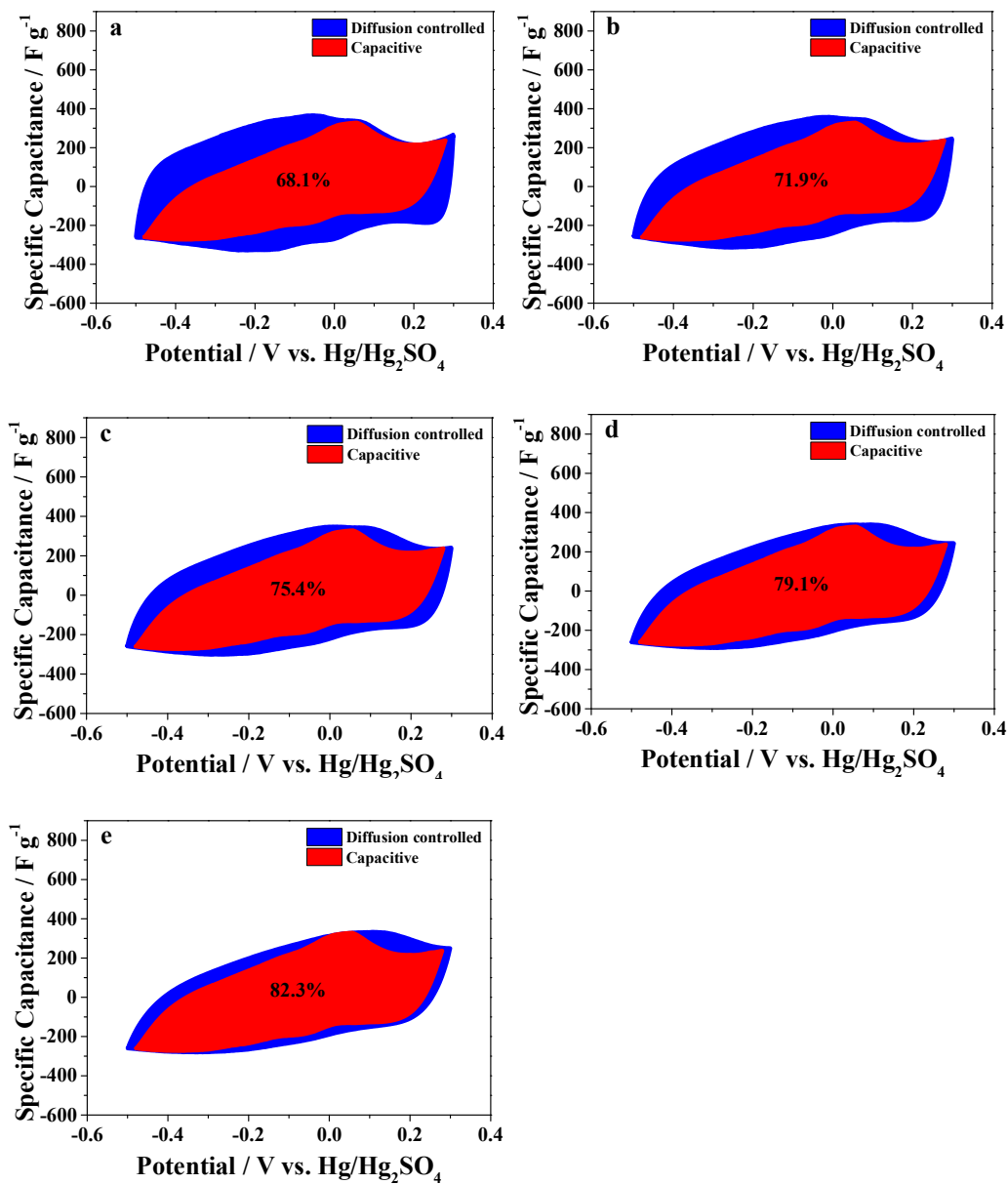


Fig. S5 The determination of capacitive contributions for PANI at (a) 10, (b) 20, (c) 30, (d) 40 and (e) 50  $mV s^{-1}$ .

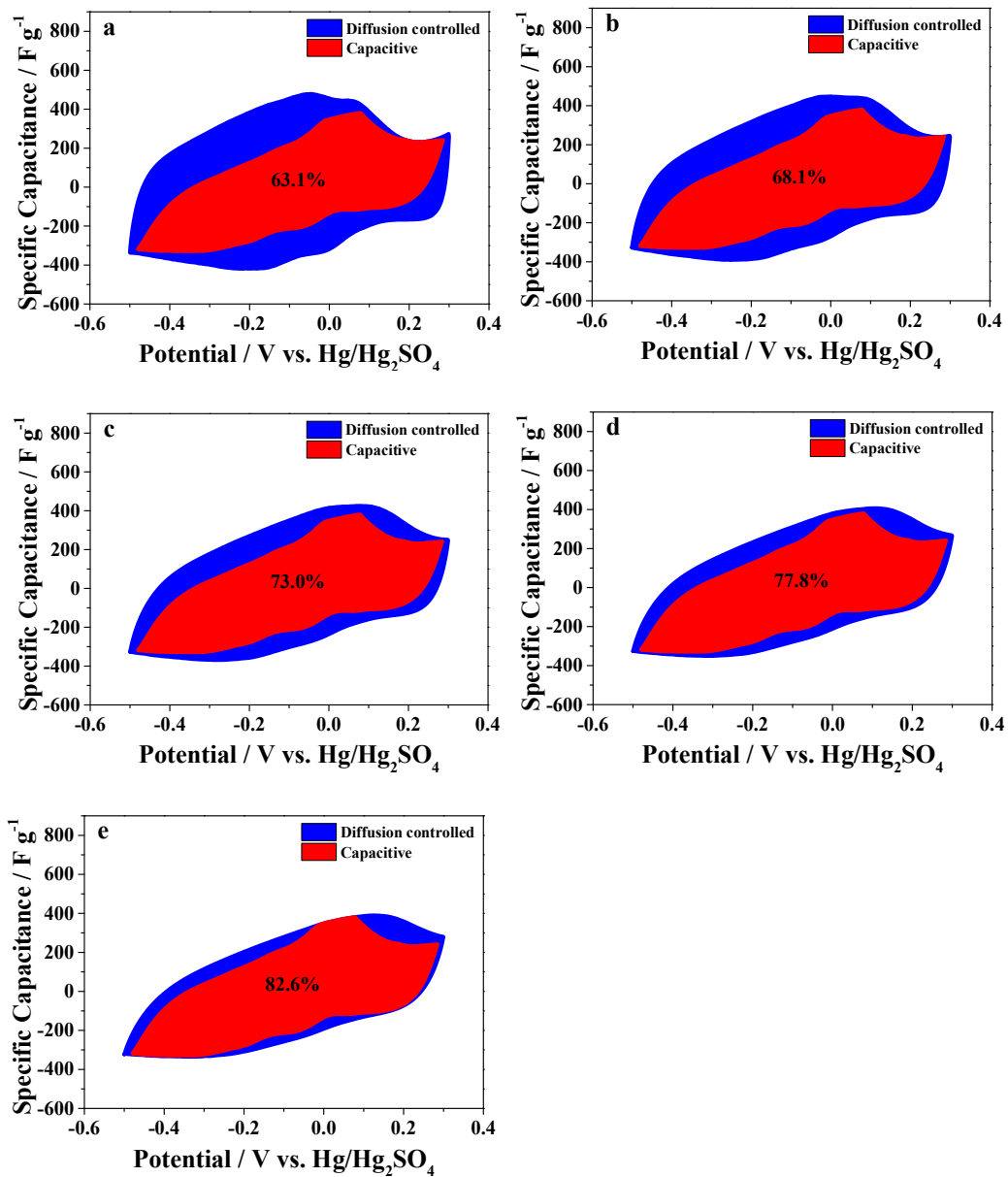


Fig. S6 The determination of capacitive contributions for PANI/P-Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> at (a) 10, (b) 20, (c) 30, (d) 40 and (e) 50 mV s<sup>-1</sup>.

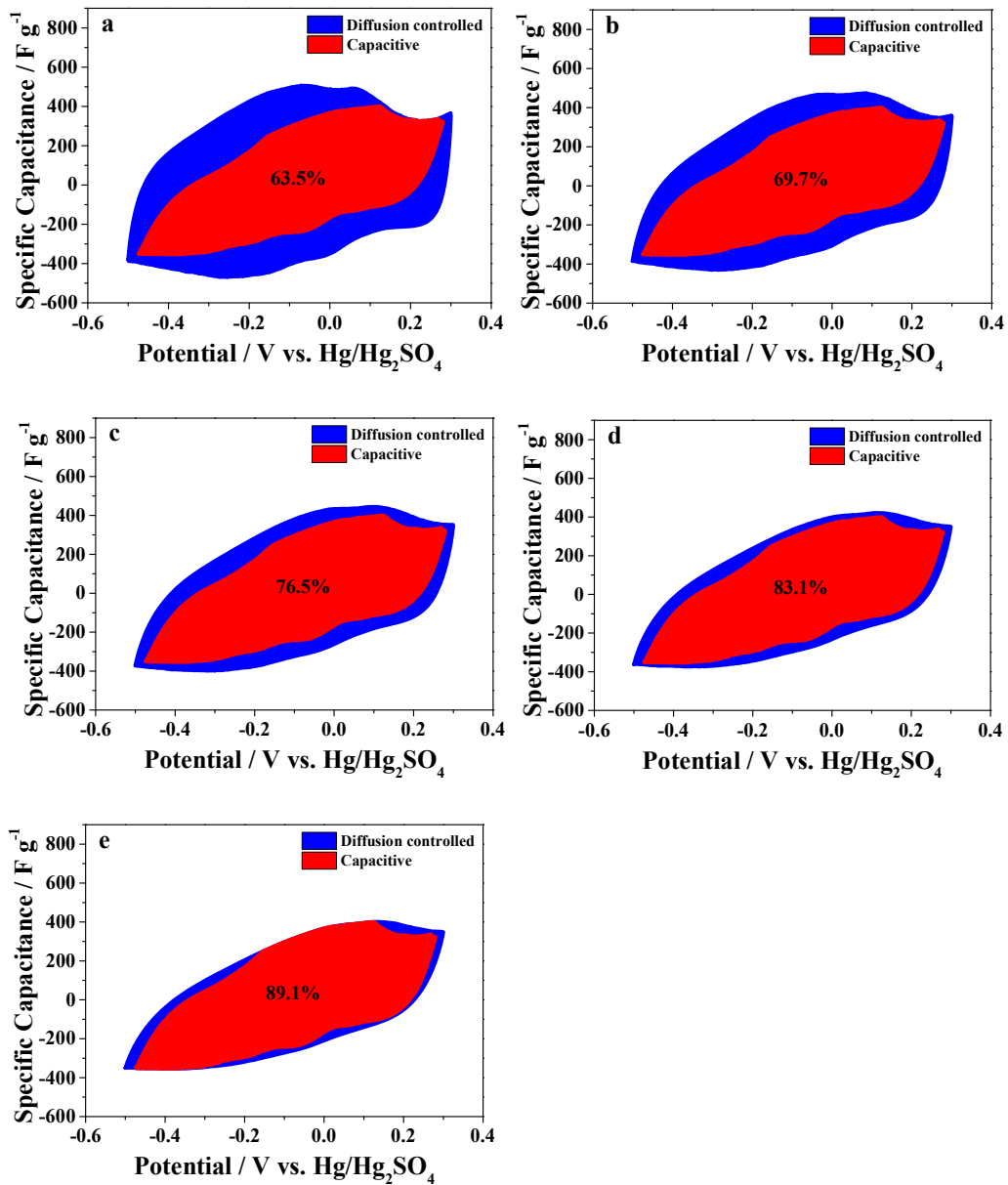


Fig. S7 The determination of capacitive contributions for PANI/H-Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> at (a) 10, (b) 20, (c) 30, (d) 40 and (e) 50 mV s<sup>-1</sup>.

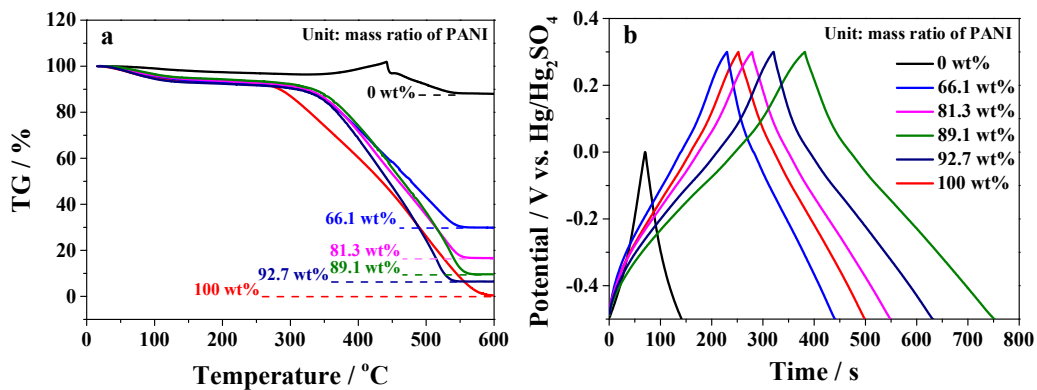


Fig. S8 The optimization of PANI/H-Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> with different mass ratio of PANI in composites: (a) TG curves. (b) GCD curves.

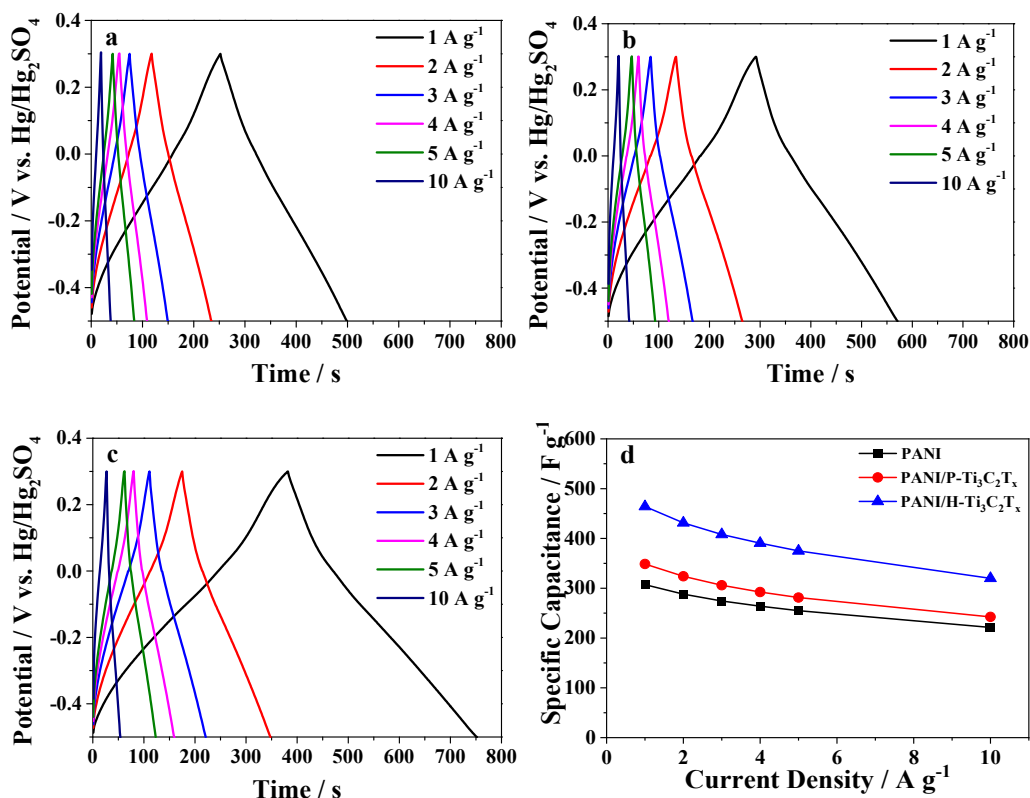


Fig. S9 Galvanostatic charge-discharge tests of PANI and PANI/Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub> at various current densities: (a) GCD curves of PANI. (b) GCD curves of PANI/P-Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub>. (c) GCD curves of PANI/H-Ti<sub>3</sub>C<sub>2</sub>T<sub>x</sub>. (d) Comparison of specific capacitances at different current densities.